Tool ID: 707 Tool Location: 103

Equipment Information Sheet

Nanostrip Tank

Manager: Phil Infante 607-254-4926 Backup: Christopher Alpha 607-254-4913 their cell phones during accessible hours. At other times leave a message or send them an email.

Calls to staff phones will be automatically forwarded to

SAFETY

- System uses Nanostrip, an aggressive oxidizing acid solution. Review MSDS for material before using.
- All chemical hood safety gear required.
- Do not strip thick waxes. Violent reaction may occur.

USAGE RESTRICTIONS SCHEDULING/SIGN-UP RESTRICTIONS

Minimum Tool Time: 0 minutes

• None

MATERIALS COMPATIBILITY CATEGORY

| Tool Category 5: Class A and B Metals and Compounds | |
|---|---|
| Allowed | Not Allowed |
| Tool category 1/1E, 2, 3, and 4 materials | |
| Silicon Based Substrates and Films | |
| III/V compound Semiconductors | |
| Glass Substrates | |
| PECVD and ALD Films | |
| Cured organics and baked Photoresist | |
| CNF Class A, B, and Refractory metals | |
| Exposed Gold, Silver, Copper | |
| Alkali and Alkaline Compounds | |
| Organic/Biology Molecules prepared- w/salt buffers | |
| High Vapor Pressure Materials (Mg, Ca, Zn)* | * Some tool restrictions on high vapor pressure materials may apply |
| Soft organic materials | |

High Vapor Pressure Metals and Compounds are materials that have a vapor pressure above 1e-6 Torr at 400 C.

Additional Material Restrictions and Exceptions

- No waxes or other thick organic films. If you are uncertain, check with staff before stripping substrates.
- Teflon boats only!

Last Updated: 05/07/2019